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L1: Entry 1 of 1

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Jun 10, 1998

DERWENT-ACC-NO: 1998-299918
DERWENT-WEEK: 200141
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TITLE: Annealing machined sintered ceramic part for use in corrosive gas - close to sintering temperature to round-off exposed machined grain edges, to prevent particle formation when used in semiconductor production

INVENTOR: AIHARA, Y; KAWASAKI, S

PATENT-ASSIGNEE: NGK INSULATORS LTD (NIGA), NIPPON GAISHI KK (NIGA)

PRIORITY-DATA: 1996JP-0339103 (December 5, 1996)

PATENT-FAMILY:

| PUB-NO | PUB-DATE | LANGUAGE | PAGES | MAIN-IPC |
|---------------|--------------------|----------|-------|------------|
| EP 846667 A2 | June 10, 1998 | E | 011 | C04B041/00 |
| US 6258440 B1 | July 10, 2001 | | 000 | B32B003/26 |
| JP 10167859 A | June 23, 1998 | | 009 | C04B041/80 |
| KR 98063777 A | October 7, 1998 | | 000 | C04B041/00 |
| TW 406293 A | September 21, 2000 | | 000 | C04B041/00 |
| KR 259572 B1 | June 15, 2000 | | 000 | C04B041/00 |

DESIGNATED-STATES: AL AT BE CH DE DK ES FI FR GB GR IE IT LI LT LU LV MC MK NL PT RO SE SI

APPLICATION-DATA:

| PUB-NO | APPL-DATE | APPL-NO | DESCRIPTOR |
|--------------|------------------|----------------|------------|
| EP 846667A2 | December 2, 1997 | 1997EP-0309690 | |
| US 6258440B1 | December 2, 1997 | 1997US-0982346 | |
| JP 10167859A | December 5, 1996 | 1996JP-0339103 | |
| KR 98063777A | December 4, 1997 | 1997KR-0065874 | |
| TW 406293A | December 1, 1997 | 1997TW-0118027 | |
| KR 259572B1 | December 4, 1997 | 1997KR-0065874 | |

INT-CL (IPC): B32 B 3/26; C04 B 41/00; C04 B 41/80; C23 F 15/00; H01 L 21/00; H01 L 21/205; H01 L 21/3065; H01 L 21/68

ABSTRACTED-PUB-NO: EP 846667A

BASIC-ABSTRACT:

A sintered ceramic part for use in a corrosive gas has a machined surface (2), where the grains have machined edges, and each of these edges is made round by material transport. Also claimed is a process for the above part whereby a body is at least ground to shape and is then annealed.

ADVANTAGE - Annealing removes microcracks, which are the starting point for corrosion, to prevent the generation of particles from aluminium nitride and alumina used inside semiconductor production equipment.

ABSTRACTED-PUB-NO: US 6258440B

EQUIVALENT-ABSTRACTS:

A sintered ceramic part for use in a corrosive gas has a machined surface (2), where the grains have machined edges, and each of these edges is made round by material transport. Also claimed is a process for the above part whereby a body is at least ground to shape and is then annealed.

ADVANTAGE - Annealing removes microcracks, which are the starting point for corrosion, to prevent the generation of particles from aluminium nitride and alumina used inside semiconductor production equipment.

CHOSEN-DRAWING: Dwg.6/7

DERWENT-CLASS: L02 L03 P73

CPI-CODES: L02-A04; L04-X;